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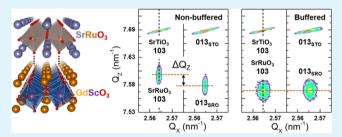


# Interfacial Octahedral Rotation Mismatch Control of the Symmetry and Properties of SrRuO<sub>2</sub>

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## Supporting Information

ABSTRACT: Epitaxial strain can be used to tune the properties of complex oxides with perovskite structure. Beyond just lattice mismatch, the use of octahedral rotation mismatch at heterointerfaces could also provide an effective route to manipulate material properties. Here, we examine the evolution of the structural motif (i.e., lattice parameters, symmetry, and octahedral rotations) of SrRuO<sub>3</sub> films grown on substrates engineered to have the same lattice parameters, but different octahedral rotations. SrRuO3 films grown on SrTiO<sub>3</sub> (001) (no octahedral rotations) and GdScO<sub>3</sub>-buffered



SrTiO<sub>3</sub> (001) (with octahedral rotations) substrates are found to exhibit monoclinic and tetragonal symmetry, respectively. Electrical transport and magnetic measurements reveal that the tetragonal films exhibit higher resistivity, lower magnetic Curie temperatures, and more isotropic magnetism as compared to those with monoclinic structure. Synchrotron-based quantification of the octahedral rotation network reveals that the tilting pattern in both film variants is the same (albeit with slightly different magnitudes of in-plane rotation angles). The abnormal rotation pattern observed in tetragonal SrRuO3 indicates a possible decoupling between the internal octahedral rotation and lattice symmetry, which could provide new opportunities to engineer thin-film structure and properties.

KEYWORDS: SrRuO3, epitaxial strain, octahedral rotation, interfacial engineering, crystal symmetry

## ■ INTRODUCTION

ABO3 perovskite oxides exhibit a diverse range of functional properties which can be readily manipulated thus making such materials candidates for a wide range of applications (e.g., logic, <sup>1,2</sup> memories, <sup>3</sup> sensing, <sup>4</sup> and photovoltaics <sup>5</sup>). The tunable nature of such materials arises from the strong coupling between charge, orbital, spin, and lattice degrees of freedom present in these systems. In films of such materials the use of epitaxial strain enables direct manipulation of the lattice degree of freedom and subsequent control of charge, orbital, and spin physics.  $^{6-8}$  Taking the canonical itinerant ferromagnetic  ${\rm SrRuO_3}$  as an example,  $^9$  ferromagnetism can be quenched under application of epitaxial strain due to a suppression of the octahedral rotations that fundamentally changes the density of states of spin-up and -down electrons at the Fermi level. <sup>10-12</sup> In turn, SrRuO<sub>3</sub>, which exhibits orthorhombic symmetry in the bulk, can be driven, under relatively large tensile or compressive strains, to exhibit tetragonal symmetry. 13,14

In addition to epitaxial strain induced by lattice mismatch, an alternative interfacial coupling effect can also take place when there exists an octahedral rotation mismatch between substrate and film.  $^{15-17}$  Due to differences in the ionic radii of the A- and B-cations and oxygen and the semi-rigidity of the oxygen octahedra cage, some perovskites exhibit octahedral rotations which can be described as a combination of rotations along three orthogonal axes ([100], [010], and [001] in the pseudocubic unit cell) with angles  $\alpha$ ,  $\beta$ , and  $\gamma$  (Figure 1a). 18-20 Using Glazer notation, the relative magnitudes of the rotation along the three axes are denoted as a, b, and c, superscripted by 0, +, or - to indicate no rotation, in-phase rotation, or out-of-phase rotation, respectively. 18 When a material with robust octahedral rotations is intimately coupled

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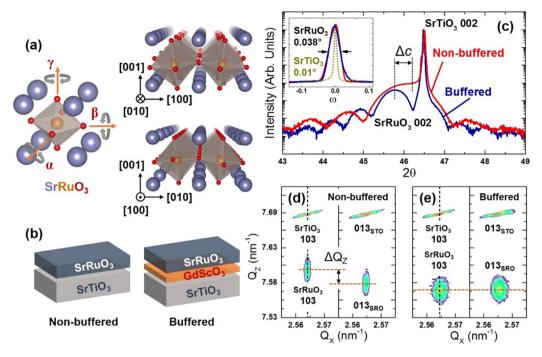


Figure 1. (a) Pseudocubic unit cell of SrRuO<sub>3</sub> including two perspective views along [010] and [100], corresponding to out-of-phase (-) and inphase (+) octahedral rotation axis, respectively. (b) Sample design for interfacial octahedral rotation mismatch studies. (c) X-ray  $\theta$ -2 $\theta$  scans about the 002 pseudocubic diffraction conditions for 10 nm thick nonbuffered and buffered SrRuO<sub>3</sub> films. Inset shows the rocking curves of the films and substrate with the corresponding full width at half-maximum values. Reciprocal space mapping studies about the 103 and 013 pseudocubic diffraction conditions of (d) nonbuffered and (e) buffered SrRuO3.

with another material that exhibits no or smaller octahedral rotations, the mismatch of atomic displacement at the heterointerface is generally accommodated by either deforming or rotating the oxygen octahedra in the film. 15,17

Despite the potential for these different modes of heterointerfacial coupling, the pervasive approach in the study of epitaxial strain has been to consider only the role of lattice mismatch-induced strain while neglecting or downplaying the role of octahedral rotation mismatch (which is hard to quantify and investigate). In fact, only in recent years have researchers started to probe the effects of such octahedral rotation mismatch in systems such as  $BiFeO_3/La_{0.7}Sr_{0.3}MnO_{3}$ ,  $^{21}LaAlO_3/SrTiO_3$ ,  $^{22}$  and  $(LaNiO_3)_n/(SrMnO_3)_m$  superlattices  $^{23}$ using state-of-the-art transmission electron microscopy and synchrotron-based X-ray diffraction. Despite these studies, a complete physical picture of such interactions and understanding of the length scales over which such effects can extend are still being developed. Nonetheless, it is becoming clear that in order to exert deterministic control over such heterostructures, knowledge of both the lattice and octahedral rotation mismatch effects are needed. This is particularly important when one considers that at room temperature most commercially available substrates used for perovskite growth possess orthorhombic  $(a^-a^-c^+)$  or rhombohedral  $(a^-a^-a^-)$ symmetry with robust octahedral rotations. 24-27 Thus, the effects of lattice mismatch could be convoluted by additional contributions from the interfacial octahedral rotation mismatch. Finally, with the increasing study of ultrathin heterostructures and superlattices, where interfacial octahedral rotation coupling could potentially play a more dominant role in controlling film properties, such understanding is essential.

In this spirit, we use SrRuO<sub>3</sub> as a model system to examine how interfacial octahedral rotation mismatch contributes to the

micro-/macroscopic structural and physical properties. In order to examine the effects of octahedral rotation mismatch alone, we explore 10 nm SrRuO<sub>3</sub> films grown directly on bare, cubic SrTiO<sub>3</sub> (001) and on 4 nm, orthorhombic GdScO<sub>3</sub>-buffered SrTiO<sub>3</sub> (001) substrates which leverages a strategy to control the lattice parameters and octahedral rotations simultaneously.<sup>28</sup> By changing the octahedral rotation mismatch at the SrRuO<sub>3</sub>/SrTiO<sub>3</sub> interface with the addition of a few nanometers of GdScO<sub>3</sub>, one can dramatically change the crystal symmetry and properties of the SrRuO<sub>3</sub>. In SrRuO<sub>3</sub>/SrTiO<sub>3</sub> (001) heterostructures, SrRuO<sub>3</sub> exhibits monoclinic lattice symmetry with strong magnetic anisotropy, and a Curie temperature (T<sub>C</sub>) of 148 K. In SrRuO<sub>3</sub>/GdScO<sub>3</sub>/SrTiO<sub>3</sub> (001) heterostructures, the SrRuO<sub>3</sub> lattice symmetry is tetragonal and the heterostructures exhibit a higher overall film resistivity, nearly isotropic in-plane magnetic behavior, and a lower  $T_C$  = 143 K. Subsequent synchrotron-based diffraction and half-order superstructure Bragg peak analyses reveal that although the lattice symmetry is changed, both the monoclinic and tetragonal variants of SrRuO3 have the same internal octahedral rotation pattern  $(a^+b^-c^-)$  albeit with a slightly smaller in-plane rotation angle in the tetragonal variant. Such an orthorhombic octahedral rotation pattern in a tetragonal lattice indicates a possible decoupling between lattice symmetry and internal octahedral rotation symmetry and highlights the significance of interfacial octahedral rotation mismatch as a potential pathway to engineer perovskite materials.

#### EXPERIMENTAL SECTION

Thin-Film Growth. All films were grown via pulsed-laser deposition. Prior to growth, the SrTiO3 substrates were treated by chemical etching and annealing following standard procedures.<sup>29</sup> The GdScO<sub>3</sub>-buffer layer was grown at 680 °C in 7.5 mTorr of oxygen with a laser fluence of 1.5 J/cm<sup>2</sup> at a repetition rate of 5 Hz (a total of 140 **ACS Applied Materials & Interfaces** 

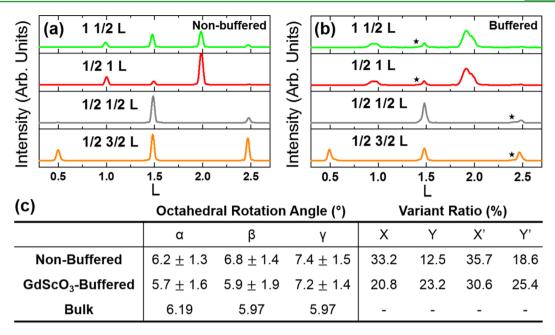


Figure 2. Four representative half-order Bragg peak diffraction patterns for 10 nm thick (a) nonbuffered and (b) buffered SrRuO<sub>3</sub>. Peaks from the GdScO<sub>3</sub>-buffer layer are marked with an asterisk (\*). (c) Experimentally measured and extracted octahedral rotation angles and domain variant fractions as obtained from the half-order Bragg peaks analysis.

pulses yielded 4 nm thick films). The  $SrRuO_3$  films were grown at 680 °C in 100 mTorr of oxygen with a laser fluence of 1.5  $J/cm^2$  and a repetition rate of 5 Hz (a total of 750 pulses yielded 10 nm thick films). Following growth, the heterostructures were cooled at 5 °C/min. in a static oxygen pressure of 760 Torr. Furthermore, to rule out the effects of varying vicinality in the  $SrTiO_3$  substrates,  $^{30}$   $SrRuO_3$  films with or without the  $GdScO_3$ -buffer layer were grown on multiple pieces of the same substrate wafer.

X-ray Diffraction Studies. Laboratory-based X-ray diffraction was completed on an X'Pert MRD Pro equipped with a PIXcel detector (PANalytical). Synchrotron X-ray scans were conducted at the Advanced Photon Source, Argonne National Laboratory on beamline 12-ID-D using the Pilatus 100 K detector, and at the Shanghai Synchrotron Radiation Facility on beamline 14B.

Electronic Transport and Magnetic Measurement. Electrical transport measurements were completed in a physical properties measurement system (PPMS; Quantum Design, Inc.). During data acquisition, samples were cooled from 300 to 25 K at 5 K/min. For magnetic measurements a magnetic property measurement system (MPMS; Quantum Design) was used. The magnetization—magnetic field hysteresis loops and magnetization—temperature profiles were obtained along two orthogonal in-plane directions (i.e., [100] and [010]) and the out-of-plane direction (i.e., [001]). In the magnetization—magnetic field measurements, samples were cooled from room temperature to 10 K in a 1 T field and held at 10 K for data acquisition. In the magnetization—temperature measurements, samples were first cooled from room temperature to 10 K in a 1 T field and then warmed at 5 K/min. to room temperature during data acquisition.

# RESULTS AND DISCUSSION

We focused on 10 nm thick films of SrRuO<sub>3</sub> (bulk SrRuO<sub>3</sub> is orthorhombic with  $a_o = 5.567$  Å,  $b_o = 5.530$  Å, and  $c_o = 7.845$  Å)<sup>31</sup> grown on SrTiO<sub>3</sub> (001) substrates (cubic, a = 3.905 Å)<sup>25</sup> [henceforth referred to as *nonbuffered SrRuO*<sub>3</sub>] and 4 nm GdScO<sub>3</sub>-buffered (bulk GdScO<sub>3</sub> is orthorhombic with  $a_o = 5.745$  Å,  $b_o = 5.481$  Å, and  $c_o = 7.929$  Å)<sup>27</sup> SrTiO<sub>3</sub> (001) substrates) [henceforth referred to as *buffered SrRuO*<sub>3</sub>]. We will use cubic or pseudocubic indices throughout unless otherwise specified (the subscript "O" will denote orthorhombic indices).

A schematic view of the heterostructures is provided (Figure 1 b). The design algorithm is based on the fact that there is expected to be much faster relaxation of octahedral rotation distortion at the heterointerface than lattice mismatch strain, <sup>16,32</sup> and thus the presence of the GdScO<sub>3</sub>-buffer layer allows for one to produce the same lattice constants (as determined by the underlying substrate), but different octahedral rotation patterns and magnitudes.

X-ray diffraction studies reveal that all SrRuO<sub>3</sub> films are fully epitaxial and single phase (Supporting Information, Figure S1). Focusing about the 002 diffraction peak of the SrRuO<sub>3</sub> (Figure 1c), the buffered SrRuO<sub>3</sub> exhibits an out-of-plane lattice parameter expansion (~0.7%) as compared with nonbuffered SrRuO<sub>3</sub>. Rocking curve studies reveal that all SrRuO<sub>3</sub> films are uniformly highly crystalline and that the addition of the buffer layer does not diminish the crystalline quality (inset, Figure 1c). Such a lattice expansion suggests a possible structural change of the buffered SrRuO<sub>3</sub>. To further understand this structural change, reciprocal space mapping (RSM) studies were completed.

RSM studies about the 103- and 013-diffraction peaks of the SrRuO<sub>3</sub> and SrTiO<sub>3</sub> (a full set of 103-type peak scans are provided, Supporting Information, Figure S2) reveal that all diffraction peaks possess the same  $Q_X$  values confirming that the films are coherently strained (Figure 1d,e). Inspection of the peak positions in the  $Q_Z$  direction reveals that the SrRuO<sub>3</sub> 103-diffraction peak has a higher  $Q_Z$  value than the 013diffraction peak for nonbuffered SrRuO<sub>3</sub> (Figure 1d), indicative of a monoclinic version of SrRuO<sub>3</sub> with  $\beta = 89.5^{\circ}$ . Additional high-resolution, synchrotron-based RSMs (Supporting Information, Figure S3a) further confirm the monoclinic structure. Inspection of the peak positions in the  $Q_Z$  direction for the buffered SrRuO3 (Figure 1e), however, reveals that the 103and 013-diffraction peaks possess the same Qz values, indicating a tetragonal version of SrRuO3, which is also supported by synchrotron-based X-ray studies (Supporting Information, Figure S3b). The observed structural change suggests that coupling effects between different octahedral rotation patterns at the heterointerface could be crucial in determining the film crystal symmetry. Such results call for a more comprehensive and detailed structural analysis.

Synchrotron-based half-order Bragg peak analysis has been used to extract octahedral rotation information in perovskite systems. 33,34 Based on this analysis, simple rules can be applied to understand the nature of the system: (1) in-phase octahedral rotations (+) will give rise to "even-odd-odd" half-order reflections, while out-of-phase octahedral rotations (-) will produce "odd-odd-odd" reflections; (2) in-phase rotations giving rise to even-odd-odd" reflections with  $k \neq l$  are an indication of an  $a^+$ -type rotation, and those with  $h \neq l$  and  $h \neq k$ are indicative of  $b^+$  and  $c^+$ -type rotations, respectively; and (3) out-of-phase rotations giving rise to odd-odd-odd reflections with  $k \neq l$  are the result of  $a^-$ -type rotations and those with  $h \neq l$ l and  $h \neq k$  are the result of  $b^-$  and  $c^-$ -type rotations, respectively. Additionally, by comparing the measured and simulated intensities of certain half-order Bragg peaks, one is able to quantitatively determine the rotation angles in the pattern. Note that due to the biaxial strain exerted on the SrRuO<sub>3</sub> by the SrTiO<sub>3</sub>, the octahedra in SrRuO<sub>3</sub> will have an elongation along the c axis. Such effects are considered in our calculation by using appropriate lattice constants for the pseudocubic SrRuO<sub>3</sub> unit cells. Furthermore, due to the orthorhombic nature of the SrRuO3 unit cell, it is possible to have four different structural domains if the material is grown on a (001)-oriented cubic substrate,<sup>30</sup> which we will denote as structural domains  $D_X$ ,  $D_Y$ ,  $D_{X'}$ , and  $D_{Y'}$ , respectively (Supporting Information, Figure S4). When we complete the fittings of the intensities of the half-order Bragg peaks, we make no a priori assumption about the makeup of the film as it pertains to these structural domains; thus, we can also extract the volumetric ratio of the different structural domains from these analyses.

Although over 100 hkl scans were performed to get accurate rotation angles and domain structures, we show (for brevity) four representative scans for each heterostructure type which are sufficient to determine the octahedral rotation patterns in the SrRuO<sub>3</sub> films. We first analyze the octahedral rotation patterns of the monoclinic, nonbuffered SrRuO<sub>3</sub> (Figure 2a). Based on the rules discussed earlier, the appearance of  $1 \frac{1}{2}$ 3/2- and 1/2 1 3/2-diffraction peaks from the SrRuO<sub>3</sub> indicates that the in-phase (+) rotation is along the [100] or [010] of the SrTiO<sub>3</sub> substrate while the peak intensity difference suggests that one structural domain is dominant. In addition, we also observe 1/2 1/2 3/2-, 1/2 3/2 3/2-, and 1/2 3/2 1/2diffraction peaks, which reveal that there are two out-of-phase rotation (-) axes that lie either in-plane or out-of-plane, but perpendicular to, the (+) axis. Therefore, we can determine that the octahedra cage in the monoclinic variant of SrRuO<sub>3</sub> is rotated along all three orthogonal directions and that the (+) axis of the rotated octahedra is aligned along either the [100] or [010] of the SrTiO<sub>3</sub> substrate resulting in two structural domains  $(D_x \text{ and } D_y)$ , albeit with one of those domains dominating. Such a preference for forming one type of domain is expected due to the miscut of the SrTiO<sub>3</sub> substrate which will tend to drive the orthorhombic c axis of the SrRuO3 to be aligned with the step edges of the substrates.<sup>30</sup>

Similar analysis can be applied to the tetragonal, buffered SrRuO<sub>3</sub>. First, the appearance of half-order Bragg peaks from the GdScO<sub>3</sub>-buffer layer next to those from the SrRuO<sub>3</sub> (marked with asterisks (\*), Figure 2b) suggests that both layers possess a similar octahedral rotation pattern and domain structure. We note that there are additional half-order Bragg peaks from the GdScO<sub>3</sub> which are not marked due to their low intensity on the data scale provided here, but these peaks are present and have been analyzed. Further analysis of the GdScO<sub>3</sub>-buffer layer reveals that it exhibits bulk-like monoclinic lattice symmetry as suggested by the increasing out-of-plane diffraction peak position difference as compared to the tetragonal SrRuO3 as one moves to higher hkl indices (Supporting Information, Figure S5). In other words, the octahedral rotation pattern of the substrate is different when the 4 nm GdScO<sub>3</sub>-buffer layer is included in the heterostructure. Upon turning our attention to the half-order Bragg peaks arising from SrRuO3, however, the fitting suggests that the octahedral rotation pattern in this tetragonal variant of SrRuO<sub>3</sub> is the same as that in the monoclinic variant of nonbuffered SrRuO<sub>3</sub>. At the same time, the structural domain pattern of the tetragonal, buffered SrRuO3 is changed as indicated by nearly equivalent peak intensities for the 1 1/2 3/2- and 1/2 1 3/2-diffraction peaks, indicating that the  $D_X$  and  $D_{\rm y}$  structural domains have similar volumetric fractions. To summarize, using the buffer-layer approach, we can effectively tune the nature of the octahedral rotation pattern of the substrate to be different, while maintaining the same in-plane lattice parameters. In turn, this results in a change in the lattice symmetry of the SrRuO<sub>3</sub> and the structural domain fractions but does not change the octahedral rotation patterns. From here, we can further extract quantitative values for the nature of these octahedral rotations.

As noted previously, comparison of the calculated peak intensities of a full range of half-order hkl scans with the experimental data provides a route to extract the octahedral rotation angles and structural domain fractions for the system. 23,33,34 The fitted half-order hkl scans for nonbuffered and buffered SrRuO<sub>3</sub> are provided (Supporting Information, Figures S8 and S9, respectively), and the extracted rotation angles and structural domain fractions are provided (Figure 2c). For monoclinic, nonbuffered SrRuO<sub>3</sub>, the rotation angles along the three orthogonal axes are extracted to be  $\alpha = 6.2 \pm 1.3^{\circ}$  (inplane (+) axis),  $\beta = 6.8 \pm 1.4^{\circ}$  (in-plane (-) axis), and  $\gamma = 7.4$  $\pm 1.5^{\circ}$  (out-of-plane (-) axis). Two majority structural variants  $(D_x \text{ and } D_{x'})$  occupying ~70% of the volume are observed. Therefore, the octahedral rotation patterns can be determined to be  $a^+b^-c^-$  or  $a^-b^+c^-$ . For comparison, in bulk SrRuO<sub>3</sub> the rotation pattern is  $a^+c^-c^-$  with  $\alpha_{\text{bulk}} = 6.19^\circ$  and  $\beta_{\text{bulk}} = \gamma_{\text{bulk}} =$ 5.97°. 23,31 Thus, in monoclinic, nonbuffered SrRuO3, the octahedral rotation angle in the in-plane (+) axis is similar to the bulk value, but the rotations in the two (-) axes, especially the one along the [001] of SrTiO<sub>3</sub>, are considerably larger and the down-selection of structural domains is consistent with prior work.<sup>30</sup>

Similarly, for tetragonal, buffered SrRuO<sub>3</sub>, the rotation angles are extracted to be  $\alpha = 5.7 \pm 1.6^{\circ}$ ,  $\beta = 5.9 \pm 1.9^{\circ}$ , and  $\gamma = 7.2 \pm 1.9^{\circ}$ 1.4°, which are slightly smaller than those in the monoclinic, nonbuffered variant. Surprisingly, four structural domains ( $D_X$ )  $D_{Y}$ ,  $D_{X'}$ , and  $D_{Y'}$ ) are found to occupy similar volumetric fractions in the films. Based on the preceding discussion, the octahedral rotation pattern of tetragonal SrRuO3 can also be represented as  $a^+b^-c^-$  or  $a^-b^+c^-$ . As compared to monoclinic, nonbuffered SrRuO<sub>3</sub>, however, in the tetragonal variant the outof-plane (–) axis octahedral rotation remains the same but the two in-plane rotation angles are slightly reduced. Such a decrease in the in-plane octahedral rotation angles results in an **ACS Applied Materials & Interfaces** 

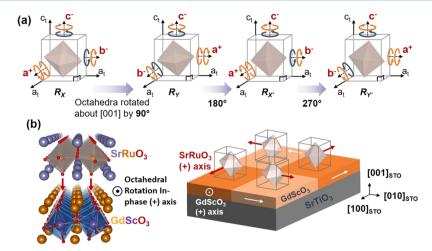


Figure 3. (a) Schematic illustration of the four octahedra "rotational" domains  $(R_X, R_Y, R_{X'}, \text{ and } R_{Y'})$  possible in the tetragonal variant of SrRuO<sub>3</sub> where the various rotational domains can be thought of as rotating the octahedra within the lattice about the [001] by 0°, 90°, 180°, or 270°. (b) Illustration of the tendency of the SrRuO<sub>3</sub> to align its in-phase (+) rotation axis with the GdScO<sub>3</sub> (+) rotation axis during growth and the corresponding coupling between GdScO<sub>3</sub> structural domains and SrRuO<sub>3</sub> rotational domains. The white arrows show the direction of the in-phase (+) octahedral rotation axis.

out-of-plane lattice expansion, while the unchanged  $\gamma$  angle suggests that the octahedral rotation along the out-of-plane axis is mainly controlled by lattice mismatch.

What is more surprising is the observation of four structural domains in the tetragonal variant. As the lattice possesses 4-fold symmetry about the [001], only one structural variant should be allowed. Fitting of the half-order Bragg peaks, however, suggests the presence of four different "structural" domains within the tetragonal lattice. These structural domains are the result of different octahedral rotation patterns in the films which, in turn, give rise to a number of half-order diffraction peaks which can be fit. From the fit, we observe four uniquely different octahedral rotation patterns where the octahedra can rotate about the [001] by 0°, 90°, 180°, or 270°, thus giving rise to what we will refer to as "rotational" domains  $R_X$ ,  $R_Y$ ,  $R_{X'}$ , and  $R_{V'}$  (Figure 3a). In other words, the combination of RSM and half-order Bragg peak analyses suggest that, in tetragonal SrRuO<sub>3</sub>, it is possible to rotate the nature of the octahedral rotation independently within the lattice. The fits also reveal a nearly equivalent volume fraction of the different rotational domains (Figure 2c). We propose that this arises due to the presence of a number of rotational domains in the GdScO<sub>3</sub>buffer layer. As is common, when an orthorhombic material is grown on a cubic substrate, multiple structural variants are formed. In this case, although the results suggest that the GdScO<sub>3</sub> has an octahedral rotation pattern similar to that of SrRuO<sub>3</sub>, exact fitting of this pattern is difficult because of large changes in the rotation pattern in GdScO3 which is confined between nonrotated (SrTiO<sub>3</sub>) and rotated (SrRuO<sub>3</sub>) materials. In turn, we hypothesize that the presence of various rotational domains in the GdScO3 results in uniform epitaxial growth of the tetragonal variant of SrRuO<sub>3</sub>, but separation of the SrRuO<sub>3</sub> in four different rotational domains as dictated by the local octahedral rotation alignment in the GdScO<sub>3</sub>-buffer layer which tends to drive the in-phase (+) rotation axis in the GdScO<sub>3</sub> and SrRuO<sub>3</sub> to be aligned (Figure 3b).

In the theory proposed by Glazer<sup>18</sup> that relates the octahedral rotation network and the lattice symmetry, a three-tilt system is expected to have lower lattice symmetry (e.g., triclinic or orthorhombic). For a high-symmetry lattice (e.g., tetragonal), however, it is thought that the octahedra are

only allowed to rotate along one axis (i.e.,  $a^0a^0c^-$ ). 35-37 In the tetragonal, buffered SrRuO<sub>3</sub>, however, we observe the presence of a three-tilting octahedral rotation pattern suggesting that the internal octahedral rotation pattern could be decoupled from the symmetry of the lattice. Similar structural changes in tensile-strained SrRuO3 have been reported before, but the results suggested no/limited decoupling between oxygen octahedra and lattice symmetry.<sup>38</sup> Moreover, due to such a decoupling of the lattice symmetry and octahedral rotation pattern, we are able to observe multiple rotational domains in a tetragonal lattice. It is important to note that such decoupling is fundamentally allowed because, within the calculation framework of Glazer, the displacement of cations is not considered, and thus the symmetry given by the octahedral network and the symmetry given by cations could potentially be considered separately. Such decoupling is likely to be a generic feature of perovskite oxide thin films, but the magnitude of this effect could vary depending on the extent of hybridization of the states arising from the A-site cation and those of the B-site and anion lattice. For instance, similar results have been reported for SrTiO<sub>3</sub> thin films grown on tensile substrates wherein the lattice appears to be tetragonal while the internal octahedral rotation pattern belongs to orthorhombic symmetry group Cmcm.<sup>39</sup> Likewise, for BiFeO<sub>3</sub> films on (LaAlO<sub>3</sub>)<sub>0.3</sub>-(Sr<sub>2</sub>AlTaO<sub>6</sub>)<sub>0.7</sub> substrates, the tetragonal lattice as probed by synchrotron radiation contains a monoclinic, polar symmetry. 40 Such findings deserve further studies and could be potentially useful in designing novel ultrathin/superlattice perovskite systems. Note that we additionally considered other potential explanations for the observed data which were subsequently ruled out or considered to be unlikely (see Supporting Information, Figures S6 and S7).

Armed with this detailed understanding of the lattice symmetry and octahedral rotations, we proceeded to explore how such effects could drive changes in the physical properties of SrRuO<sub>3</sub>. Temperature-dependent resistivity measurements from 25 to 250 K in the van der Pauw geometry<sup>41</sup> (Figure 4) reveal the high quality of the SrRuO<sub>3</sub> heterostructures as indicated by the overall low resistivity  $(10^{-5}-10^{-4}~\Omega\cdot\text{cm})$  and the relatively large ratio (4-6) between high- and low-

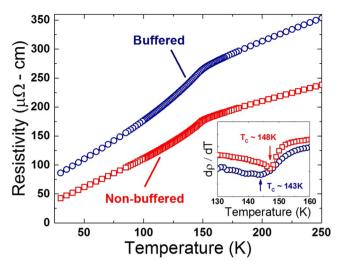


Figure 4. Temperature-dependent electrical resistivity behavior for 10 nm thick nonbuffered (red squares) and buffered (blue circles)  $SrRuO_3$  heterostructures. The inset shows  $\frac{d\rho}{dT}$  vs T curves and demarcates the  $T_C$ .

temperature resistivities  $(\frac{\rho_{250K}}{\rho_{25K}})^9$ . In general, it has been argued that epitaxial strain, <sup>12</sup> film thickness, <sup>35,42</sup> and stoichiometry <sup>43</sup> can significantly affect the film structure (i.e., Ru–O–Ru bond angle) thereby giving rise to changes in hybridization between the Ru 4d orbitals and the O 2p orbitals which will manifest in marked changes in the macroscopic electrical transport. From this work, however, in a situation where we have controlled film thickness, stoichiometry, crystallinity, and strain state to be the same, the mere insertion of the GdScO<sub>3</sub>-buffer layer (and the subsequent changes in the lattice symmetry and in-plane

octahedral rotation angles of  $SrRuO_3$ ) results in an decrease in  $T_C$  by  $\sim$ 5 K and gives rise to a large increase in the overall film resistivity (over 100% at low temperature).

We additionally studied the magnetic properties of buffered and nonbuffered SrRuO<sub>3</sub> heterostructures. Hysteresis loops for the monoclinic, nonbuffered SrRuO<sub>3</sub> (Figure 5a) reveal that the SrRuO<sub>3</sub> films have an out-of-plane easy axis that gives a saturated magnetization of  $\sim 1.46 \mu_B/\text{Ru} (\sim 225 \text{ emu/cm}^3)$  and projects anisotropically onto [100] and [010]. Additionally, a sharp magnetic phase transition was observed in the temperature dependence of the nonbuffered  $SrRuO_3$ , and the  $T_C$  was determined to be ~148 K (Figure 5b). Upon insertion of the GdScO<sub>3</sub>-buffer layer and transformation of the SrRuO<sub>3</sub> film to tetragonal symmetry, the films still exhibit an out-of-plane easy axis, but with nearly isotropic in-plane magnetic response (Figure 5c). Such isotropic magnetic behavior could be attributed to the symmetry change of the unit cell such that the easy axis is more aligned with the out-of-plane axis. Additionally, we note that the presence of multiple rotational domain variants in these samples could also give rise to an effectively averaged magnetic response in the buffered SrRuO3 which could also contribute to the more isotropic in-plane magnetization. Additionally, the out-of-plane magnetization was also found to be decreased to  $\sim 1.06 \mu_B/\text{Ru} (\sim 165 \text{ emu/cm}^3)$ . In SrRuO<sub>3</sub>, the magnetization is strongly coupled with the orthorhombicity of the unit cell, and as has been calculated,<sup>44</sup> increasing the unit cell symmetry from orthorhombic to cubic will lower the ground-state magnetic moments. Thus, the smaller saturated magnetic moments that we observed in the SrRuO<sub>3</sub> films grown on buffered SrTiO<sub>3</sub> are consistent with an increase in the symmetry of the film. Likewise, in the tetragonal variant of SrRuO<sub>3</sub>, a reduction of  $T_C$  to ~143 K was observed

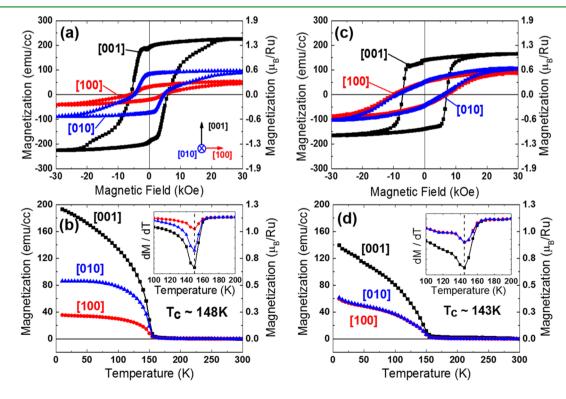


Figure 5. Magnetization—magnetic field and magnetization—temperature results for 10 nm thick (a, b) nonbuffered and (c, d) buffered SrRuO<sub>3</sub> heterostructures. All samples are cooled at 1 T field from room temperature to 10 K prior to study.

(Figure 5d), consistent with the observations from the electronic transport.

#### CONCLUSION

In summary, we have demonstrated that for buffered and nonbuffered SrRuO3 films, even under the same lattice mismatch strain, one is able to change the film lattice symmetry and corresponding electrical and magnetic behavior by changing the interfacial octahedral rotation patterns. Detailed structural studies via half-order Bragg peak analysis have revealed that the octahedral rotation pattern of buffered and nonbuffered  $SrRuO_3$  are both  $a^+b^-c^-$ , while the in-plane octahedral rotation angles are reduced in those grown on nonbuffered substrates and nearly equal fractions of "rotational" domain are observed. The observed  $a^+b^-c^-$  octahedral rotation pattern in tetragonal variants of SrRuO<sub>3</sub> suggests that the symmetry of the octahedral rotation network as described by Glazer can actually be decoupled from the symmetry of the overall lattice. These results, in turn, provide new insights into novel ways of engineering structure and physical properties of perovskite thin films and lead to better understanding of the interaction between strain, octahedral behavior, and crystal symmetry in perovskite oxide thin films.

### ASSOCIATED CONTENT

### **S** Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsami.6b02864.

Additional X-ray diffraction studies and structural variants, GdScO<sub>3</sub>-buffer-layer structure, additional evidence for tetragonal lattice symmetry in buffered SrRuO<sub>3</sub> films, and SrRuO<sub>3</sub> octahedral rotation angles and domain structure determination (PDF)

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#### **Notes**

The authors declare no competing financial interest.

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